	Application No.	Applicant(s)
Notice of Allowability	09/900,688	PINARBASI, MUSTAFA
	Examiner	Art Unit
	Christopher R. Magee	2627
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. A This communication is responsive to		
2. The allowed claim(s) is/are <u>1-6,18-22 and 31-35</u> .		
 3. ☐ Acknowledgment is made of a claim for foreign priority units. a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have 		
2. Certified copies of the priority documents have been received in Application No		
3. Copies of the certified copies of the priority documents have been received in this national stage application from the		
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached		
1) hereto or 2) to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. Notice of Informal B	atont Application (RTO 152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☑ Interview Summary	ratent Application (PTO-152)
3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/08	_ Paper No./Mail Dat	e <u>3/17/2006</u> .
Paper No./Mail Date	B), 7. ⊠ Examiner's Amendn	1ent/Comment
 Examiner's Comment Regarding Requirement for Deposit of Biological Material 	8. X Examiner's Stateme	ent of Reasons for Allowance
	9.	
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DETAILED ACTION

EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

Cancel claims 23-30 and 36-43.

Authorization for this examiner's amendment was given in a telephone interview with Mr. Robert Guillot on Friday, March 17, 2006.

REASONS FOR ALLOWANCE

2. Claims 1-6, 18-22 and 31-35 are allowed.

The following is an examiner's statement of reasons for allowance:

This application is for a METHOD FOR FABRICATING SEED LAYER FOR SPIN VALVE FOR MAGNETIC HEADS FOR HARD DISK DRIVES.

• Claim 1 specifies a seed layer, which requires:

"wherein said seed layer is a three part seed layer comprised of Al_2O_3 , NiMnO and NiFeCr, and wherein said NiFeCr seed layer has a rough top crystallographic surface that is rougher than a top crystallographic surface of a deposited NiFeCr seed layer."

• Claims 18 and 31 specify a seed layer, which requires:

"wherein said seed layer includes an Al_2O_3 layer, an NiMnO layer and an NiFeCr layer, and wherein said NiFeCr seed layer has a rough top crystallographic surface that is rougher than a top crystallographic surface of a deposited NiFeCr seed layer."

The prior art of record, Gill (US 6,430,014 B1) in view of Gill (US 6,674,616 B2) and further in view of Shukh et al. (US 6,667,616 B1), fails to fairly, teach, show or suggest, by either anticipating or rendering obvious, the invention as set forth in the claims of the instant application. Furthermore, a search made does not detect the combined claimed elements as set forth in the pending claims. Additionally, the reasons for allowance of the claims over the prior art of record is believed to be readily clear, self evident and apparent from the claim language set forth in each of claims 1, 18 and 31, when compared and contrasted with the prior art.

More particularly, the instant invention (as set forth in claims 1, 18 and 31) provides a seed layer which includes an Al₂O₃ layer, an NiMnO layer and an NiFeCr layer (i.e., a three part seed layer), and wherein said NiFeCr seed layer has a rough top crystallographic surface that is rougher than a top crystallographic surface of a deposited NiFeCr seed layer. None of the cited prior art of record, however, disclose such a seed layer as set forth in the manner, function and relationship relative to other claimed structures as prescribed by the independent claims.

3. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Conclusion

4. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Christopher R. Magee whose telephone number is (571) 272-

7592. The examiner can normally be reached on M-F, 8: 00 am-4: 30 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, William Korzuch can be reached on (571) 272-7589. The fax phone number for the

organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Patent Examiner

Art Unit 2627

March 17,2006 crm

SUPERVISORY PATENT EXAMINES

TECHNOLOGY CENTER 2600